Efficiency and harmonic enhancement trends in GaN-based Gunn diodes: Ensemble Monte Carlo analysis

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Gallium nitride can offer a high-power alternative for millimeter-wave Gunn oscillators. Hence, an ensemble Monte Carlo-based comprehensive theoretical assessment of efficiency and harmonic enhancement in n-type GaN Gunn diodes is undertaken. First, the effects of doping notch/mesa and its position within the active channel are investigated which favors a doping notch positioned next to cathode. It is then observed that the width of the notch can be optimized to enhance the higher-harmonic operation without degrading its performance at the fundamental mode. Next, the effects of dc bias and channel doping density are investigated. Both of these have more significant effects on the higher-harmonic efficiency than the fundamental one. The lattice temperature is observed to have almost no influence up to room temperature but severely degrades the performance above room temperature. As a general behavior, the variations of temperature, channel doping, and the notch width primarily affect the phase angle between the current and voltage wave forms rather than the amplitude of oscillations. Finally, the physical origin of these Gunn oscillations is sought which clearly indicates that the intervalley scattering mechanism is responsible rather than the valley nonparabolicity or the effective mass discrepancy between the Γ and the lowest satellite valleys.

Gallium nitride with its high negative differential mobility threshold, measured to be above 200 kV cm$^{-1}$, is an appealing material for high-power millimeter-wave Gunn diodes. An ever-present objective is to increase the operating frequency of the Gunn diodes, and a promising approach is to operate them at their higher harmonic modes rather than their fundamental mode. Recently, a number of researchers focused on this point addressing the dependence of the higher harmonic efficiency on the doping profile mainly referring to the mature InP technology. The literature on GaN-based Gunn diodes has not yet flourished as the main theoretical reports published on GaN Gunn diodes, Joshi et al. studied multiple-transit region effects on the output power, Liu and Cao analyzed chaotic dynamics in terahertz generation, and Gružinskis et al. considered zincblende and wurtzite phases of GaN with an additional p-doped barrier region for current limiting.

In this work, our aim is to present a comprehensive theoretical assessment of efficiency and harmonic enhancement in n-type GaN Gunn diodes, exploring the effects of doping profile, dc bias, and the lattice temperature. We would like to extract the trends rather than quantitative aspects so that our results can shed light on the physics of Gunn oscillations based on other materials as well. We employ the ensemble Monte Carlo (EMC) technique which has been previously tested in the analysis of InP Gunn diodes.

In a similar work on GaN, Joshi et al. used the energy geometries of GaN Gunn diodes with an additional p-doped barrier next to cathode and a lightly n-doped doping notch having $n=-1$×10$^{19}$ cm$^{-3}$ or a doping mesa with $n=5×10^{17}$ cm$^{-3}$. Our EMC simulations start from a charge–neutral configuration, and unless otherwise stated, are at 300 K. As a standard practice in modeling Gunn diodes (see, Ref. 7 and use more realistic bandstructure data that place the $U$ valley 1.34 eV above the conduction-band minimum. All major scattering mechanisms are taken into account, while the scattering tables are formed based on the pseudopotential density of states of GaN. For further details of the parameters, we refer the reader to our previous work.

The types of structures we study are shown in Fig. 1. The overall active region length is always kept constant at a value of $L=1.2$ μm. This active region is sandwiched between the heavily doped $n^+$ regions with $n^+=2×10^{18}$ cm$^{-3}$; the results were seen to be unaffected when this is increased to $1×10^{19}$ cm$^{-3}$. The active region is composed of an active channel with a doping of $n=3×10^{17}$ cm$^{-3}$ (unless stated otherwise) and a lightly n-doped doping notch having $n=-1$×10$^{19}$ cm$^{-3}$ or a doping mesa with $n=5×10^{17}$ cm$^{-3}$.

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FIG. 1. The types of GaN-based Gunn structures studied: (a) Notch/mesa placed next to cathode and (b) notch/mesa placed in the middle of the active region.

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references therein), a single-tone sinusoidal voltage of the form \( V_{dc} + V_{ac} \sin(2\pi ft) \) is imposed across the structure; if not stated, we use \( V_{dc} = 60 \text{ V} \) and \( V_{ac} = 15 \text{ V} \). This choice significantly simplifies our frequency performance assessment. Moreover, its validity was checked by relaxing the imposed single-tone sinusoidal voltage across the Gunn diode and connecting it to an external tank circuit with the voltage across the device being self-consistently updated at each simulation step through solving the Gunn diode and the external circuit.\(^{14}\) For both cases, the phase relations were found to be very similar.\(^{14}\) To assure that both amplitude and phase have stabilized, simulations are lasted for at least 0.2 ns. The current waveform is sampled at every 80 fs while the simulation time step is 0.4 fs.

The oscillator efficiency, is defined as \( \eta = p_{ac}/P_{dc} \), where \( P_{ac} \) is the time-average generated ac power and \( P_{dc} \) is the dissipated dc power by the Gunn diode. First, the effect of the doping notch width positioned next to cathode, c.f. Fig. 1(a) is investigated. It is observed that there is an optimum notch width, for our case, around a value of 80 nm, at which the second-harmonic efficiency approaches that of the fundamental mode value as seen in Fig. 2(a). Here, the fundamental mode corresponds to the frequency \( u_{d,\text{sat}}/\ell_\alpha \) for a given active region length \( \ell_\alpha \), where \( u_{d,\text{sat}} \) is the saturation drift velocity; in the \( n \)th harmonic mode there exist \( n \) Gunn domains traveling down the channel at each instant.\(^{14}\) However, we would like to point out that the value of the optimum notch width is sensitive to the material parameters and our previous analysis with the bandstructure data of Ref. 10 resulted in a wider width.\(^{14}\) On the other hand, a doping mesa rather than a notch was suggested to enhance the harmonic content of the current waveform.\(^{4,6}\) To elucidate this point, Fig. 2(b) compares the performance of four configurations made from the combinations of notch/mesa placed next to cathode and in the middle of the active region. It is seen that notch placed next to cathode (labeled as 1) performs the best among all. A source of curiosity regarding Fig. 2(b) is the substantial frequency shift for the notch placed in the middle (labeled as 3) and mesa placed next to the cathode (labeled as 2). A detailed time-domain investigation of these structures shows that for both cases almost half of the active region is inactive in the domain nucleation processes, hence remarkably decreasing the transit time of the Gunn domains.

In Fig. 3, the effects of dc bias and channel doping are displayed. While changing the applied dc voltage, we need to scale the rf amplitude accordingly not to lose the grounds for efficiency comparison. The applied dc voltage has to be above a critical value so that the device is biased in the negative differential mobility regime. Therefore, increasing bias has favorable effect on the fundamental and harmonic efficiencies. The channel doping on the other hand is relatively less influential on the fundamental mode efficiency than the higher harmonic modes, so that for a given notch width and bias voltage, there is an optimum channel doping that favors the harmonic enhancement. However, there is a...
lower threshold for the channel doping as it determines the dielectric domain nucleation time that needs to be much shorter than the domain transit time through the active region.\textsuperscript{19}

For high power Gunn diodes, thermal heating can be an important issue. At the expense of neglecting thermal gradient effects, we simply consider the uniform lattice temperature effects on the efficiency. As can be observed in Fig. 4(a), up to room temperature, there is no sensible variation, whereas above the room temperature performance increasingly degrades becoming passive above 480 K in the case considered. The source of this degradation is not due to a reduction in the oscillation amplitudes but rather due to phase angle between the current and voltage wave forms shifting away from antiphase (180°) to orthogonal (90°) and finally towards dissipative (0°) while the temperature increases. As a matter of fact, the phase angle difference is always far below 180° due to the finite capacitance of the Gunn diode which is not cancelled by an external inductor under the imposed single-tone sinusoidal bias condition that is employed in this work. Figure 4(b) further illustrates that the increase in the lattice temperature does not significantly shift the frequency but diminishes the efficiency globally. Therefore, good heat sinking is required in these diodes.

On the physical origin of the Gunn oscillations, there exists a number of possible sources, such as the Γ valley nonparabolicity, intervalley transfer mechanism to satellite valleys, and, as recently suggested,\textsuperscript{11} ballistic transport through the Γ valley band inflection point when located below the lowest satellite valley energy. In our EMC treatment, which is essentially based on spherical bands hence without any band inflection points, this last choice cannot play a role. To identify the effect of Γ valley nonparabolicity, switching to a parabolic band further increases the rf generation efficiency whereas increasing the nonparabolicity decreases it. This rules out the fact that it can be the cause, and one can reason it as the nonparabolicity delaying the electrons under the electric field’s acceleration from reaching the satellite valley energy. On the effective mass discrepancy, the lowest satellite $U$ valley is more than twice as heavy as the Γ valley\textsuperscript{15} which advocates the transfer from a light to a heavy band as an additional driving mechanism. Interestingly, equating these two masses decreases the efficiency somewhat but it does not quench it. As a matter of fact, we identified the optical deformation potential field which leads to intervalley scattering as the most important parameter that controls the efficiency. Fortunately, its value for GaN has recently been rigorously determined by Akis \textit{et al.}\textsuperscript{20}

In summary, we have analyzed the trends in efficiency and harmonic enhancement in GaN Gunn diodes under doping profile, bias, and temperature variations. The key parameter in all these efficiency considerations has been the phase angle difference between the current and voltage waveforms. Our extensive simulations indicate that the carrier dynamics in GaN can be tailored by an optimum choice of doping profile, temperature, and bias conditions so that the efficiency of higher harmonic Gunn oscillations can be boosted.

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